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Standard Specification for Chromium Sputtering Targets for Thin Film Applications¹

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1. Scope

1.1 This specification covers sputtering targets fabricated from chromium metal.

1.2 This specification sets purity grade levels, physical attributes, analytical methods and packaging requirements.

1.3 The values stated in SI units are regarded as standard.

2. Referenced Documents

2.1 *ASTM Standards*:²

E112 Test Methods for Determining Average Grain Size

3. Terminology

3.1 *Definitions of Terms Specific to This Standard*:

3.1.1 *raw material lot*—original material lot from which a number of targets is fabricated.

3.1.2 *relative density, n*—actual target density divided by the theoretical density of chromium, 7.21 g/cm³.

4. Classification

4.1 Grades of chromium are defined in Table 1.

4.2 Grade, as defined in Table 1, is based on the total metallic impurity content of the metallic elements listed in Table 2. Elements not detected shall be counted and reported as present at the detection limit.

5. Ordering Information

5.1 Orders for these targets shall include the following:

5.1.1 Grade,

5.1.2 Configuration, (see 8.1 and 8.2),

5.1.3 Whether certification is required, (see 12.1), and

5.1.4 Whether a sample representative of the finished product is required to be provided by the supplier to the purchaser.

¹ This specification is under the jurisdiction of ASTM Committee F01 on Electronics and is the direct responsibility of Subcommittee F01.17 on Sputter Metallization.

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² For referenced ASTM standards, visit the ASTM website, www.astm.org, or contact ASTM Customer Service at service@astm.org. For *Annual Book of ASTM Standards* volume information, refer to the standard's Document Summary page on the ASTM website.

TABLE 1 Chromium Grades^A

Grade	Implied Purity, %	Metallic Impurity Level by Weight, ppm, max
4N	99.99	100
3N7	99.97	300
3N5	99.95	500
3N	99.9	1000
2N8	99.8	2000

^AAdditional grades may be designated by following the same pattern. That is, examine the purity expressed in weight percent. Count the leading, "9's" and set this number as "n". Then note the first following digit, if present, (rounded if necessary) and call this numeral "x". The grade is expressed as "nNx".

6. Chemical Composition

6.1 The metallic elements listed in Table 2 shall be assayed and reported.

6.2 Gaseous elements to be assayed and reported are C, O, N and S.

6.3 Other elements may be assayed and reported as agreed upon between the purchaser and the supplier, but these shall not be counted in determining the grade designation.

6.3.1 Acceptable limits and analytical techniques for additional elements shall be agreed upon between the purchaser and the supplier.

7. Physical Properties

7.1 Minimum relative density shall be agreed upon by the purchaser and the supplier.

7.2 Actual target density shall be determined by Archimedes principle or other acceptable techniques.

7.3 Grain size shall be agreed upon between the purchaser and the supplier, and reported in accordance with Test Method E112.

8. Dimensions, Mass, and Permissible Variations

8.1 Each target shall conform to an appropriate engineering drawing.

8.2 Nominal dimensions, tolerances and other attributes shall be agreed upon between purchaser and supplier.

9. Workmanship, Finish and Appearance

9.1 Workmanship, finish and appearance shall be agreed upon between the purchaser and the supplier.